

INFORMATION DISCLOSURE CITATION IN AN APPLICATION

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 APPLICANT
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GROUP

 U.S. PTO
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U.S. PATENT DOCUMENTS

EXAMINER'S INITIALS	PATENT NO.	DATE	NAME	CLASS	SUBCLASS	FILING DATE
GH	5,650,261	7/97	Winkle	430	270.1	10-27-89
GH	5,714,628	4/98	Matsuo	430	323	6-30-95
GH	4,869,995	9/26/89	Shirai et al.	430	270.1	
GH	4,775,609	10/4/88	McFarland	430	330	
GH	5,015,559	5/14/91	Ogawa	430	326	
GH	5,278,029	1/11/94	Shirai et al.	430	323	

FOREIGN PATENT DOCUMENTS

EXAMINER'S INITIALS	PATENT NO.	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
						Yes	No
GH	0 691 674	1/10/96	Europe	—	—		
GH	0 515 212	11/25/92	Europe	—	—		
GH	0 519 128	12/23/92	Europe	—	—		

OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)

GH	"Photosensitive Polymers Bearing Iminooxysulfonyl Groups. A Water Soluble Positive-Type Photoresist", by Shirai et al, Die Markomol. Chemie. Macromolecular Chemistry and Physics, Vol. 90, No. 9, pp. 2099-2107 (1989).
GH	Shirai et al, 114:63167, Chemical Abstracts, America Chemical Society, Columbus, Ohio, Abstract of J. Appl. Polym. Sci. (1990), Vol. 41, No. 9-10, pp. 2527-2532.

EXAMINER

DATE CONSIDERED

9-27-00